ostitute for form 1449A/PTO (modified)	Application Number	09/990604
NFORMATION DISCLOSURE	Filing Date	November 21, 2001
STATEMENT BY APPLICANT	First Named Inventor	Brady, John T.
1000	Art Unit	1712
(Use as many sheets as necessary)  AUG 1 3 2004	Examiner Name	Daniel S. Metzmaier
Page 1 of	Attorney Case Number	57029US002

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